

## Supplementary Information

### S1. Temperature selection for a-C-to-graphene transformation

In order to define the temperature for studying the diffusion behavior, the Ni@a-C system with Ni/C atomic ratio of 1/1 is used. The temperature increases from 300 to 2400 K by stepwise heating method, and the system is diffused at each temperature for 100 ps. At each temperature, the diffusion behavior of C and Ni atoms and corresponding structural evolution of Ni@a-C system are evaluated.

#### Evolution of Kinetic energy (KE) and potential energy (PE)

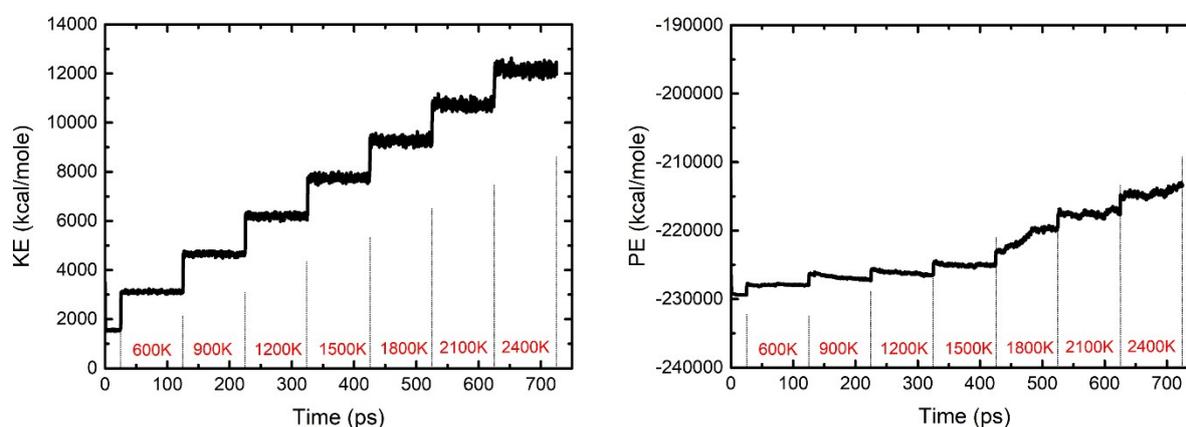


Fig. S1. Evolution of both kinetic energy (KE) and potential energy (PE) as a function of diffusion time.

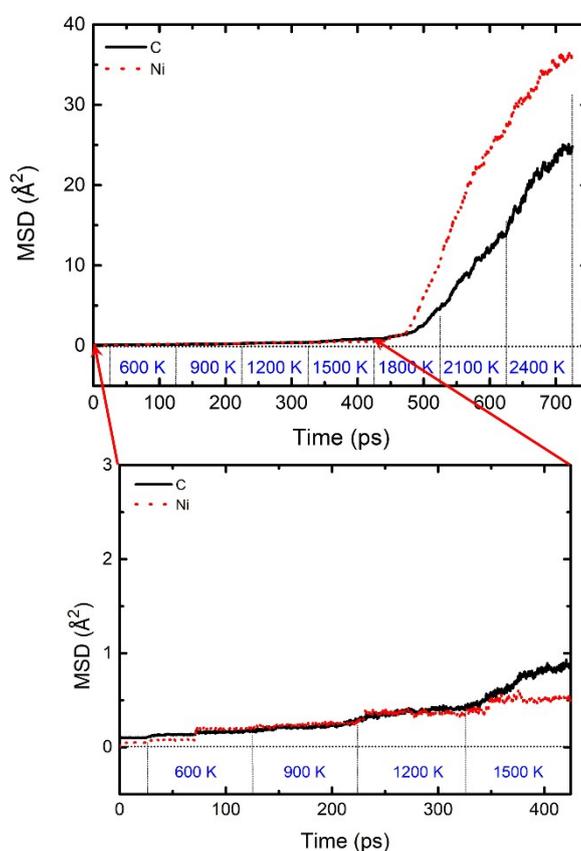
#### Diffusion behavior and structural transformation at different temperatures

In order to evaluate the diffusion behavior at each temperature, the mean-squared displacement (MSD) is estimated as follows:

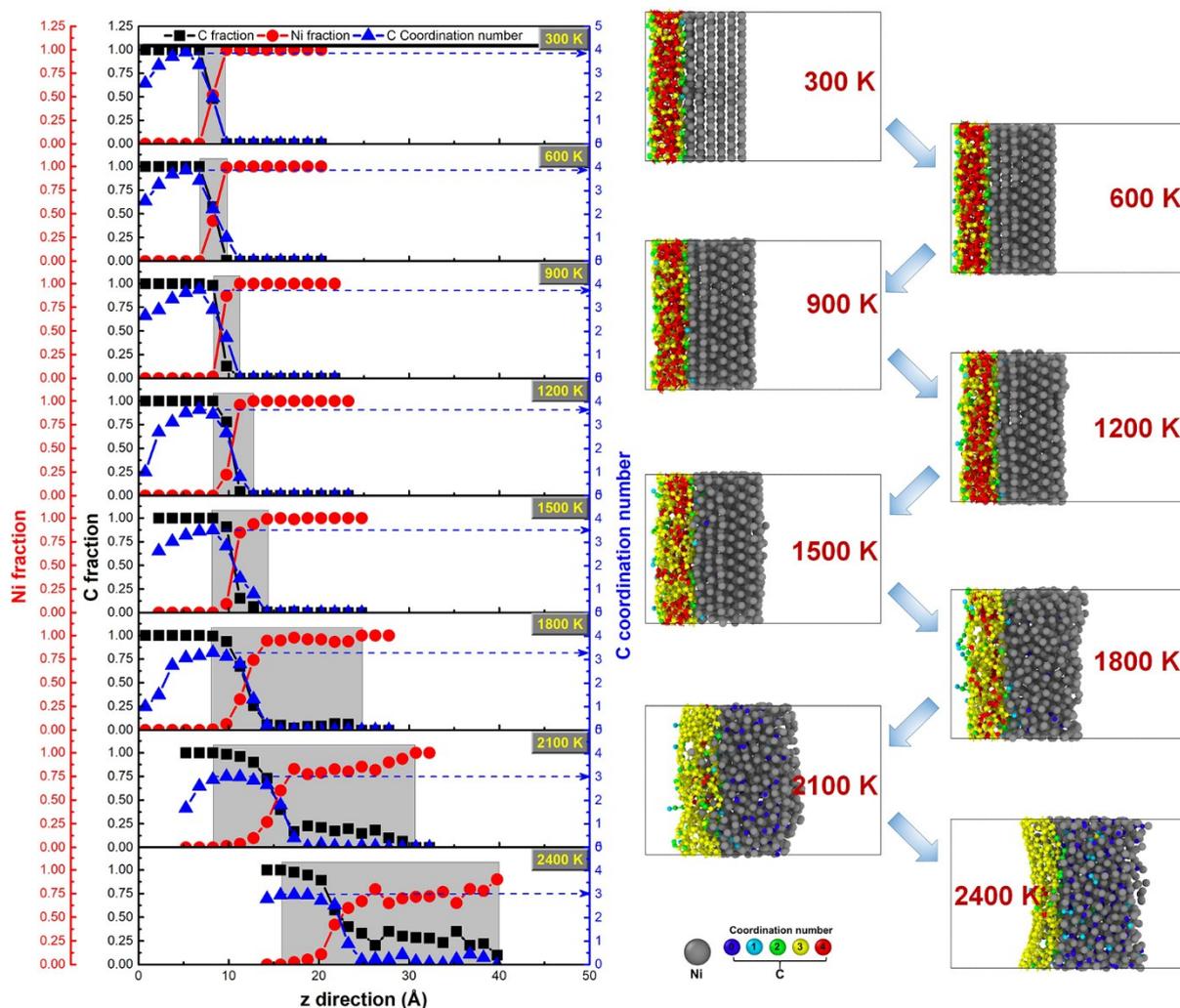
$$\text{MSD} = r^2(t) = \frac{1}{N} \left\langle \sum_{i=1}^N |r_i(t) - r_i(0)|^2 \right\rangle \quad (1)$$

where,  $N$  is the number of  $i$  atoms in the system,  $r_i(t)$  is the position of the  $i$  atom at  $t$  moment, and  $r_i(0)$  is the position of the  $i$  atom at  $t=0$  moment. From the MSD (Fig. S2) and the change in C and Ni atomic fractions along the diffusion couple direction (Fig. S3), we find that at 300K, the clear sharp interfaces separating a-C and Ni can be observed. When the temperature is located at the range of 300~1500 K, the

interatomic interaction already causes some local atomic movement at the interface, the atoms at interface mix together and the sharp interface becomes a bit fuzzy (Fig. S3), so the obvious C-Ni transition layer is formed, while the MSD for Ni or C almost has no change, indicating the solid state of a-C and Ni layers. As increasing the temperature to 1500 K, the MSD curves for C and Ni atoms begin to increase obviously with diffusion time, but there are still only few C atoms diffusing into Ni layers during the time of 100 ps. With the temperature further increased to be higher than 1500 K, the MSD for C and Ni atoms increase significantly and more C atoms can further diffuse into Ni structure to form a diffusion zone, indicating the serious change in structure.



**Fig. S2.** MSD for C and Ni atoms as a function of diffusion time at each temperature.



**Fig. S3.** Distributions of C and Ni atomic fractions along the diffusion couple direction and corresponding morphologies after diffusion time of 100 ps at each temperature.

Fig. S4 gives the change in 4- and 3-coordinated C fractions with temperature. It can be seen that when the temperature increases from 300 to 1800 K, the 3-coordinated C fraction increases significantly following the decrease of 4-coordinated C fraction; however, as the temperature further reaches to be higher than 1800 K, the dissolution of graphitic structure into Ni layer causes the reduction of 3-coordinated C fraction, which is not favorable to the formation of graphene structure. Based on the abovementioned analysis of diffusion behavior of C and Ni atoms and the evolution of hybridization structure, the temperature to study the a-C-to-graphene transformation is suggested to be  $1500 \leq T \leq 1800$  K. However, by further extending the diffusion time of system at 1500 or 1800 K to 1350 ps, Fig. S5

illustrates that more C atoms diffuse into Ni layer when the temperature is 1800 K, while only few C atoms diffuse into Ni layer at 1500 K. Therefore, in order to investigate the diffusion of C into Ni and the a-C-to-graphene transformation during the short molecular dynamics (MD) simulation time, the temperature of 1800K is adopted in the present work for the following calculations.

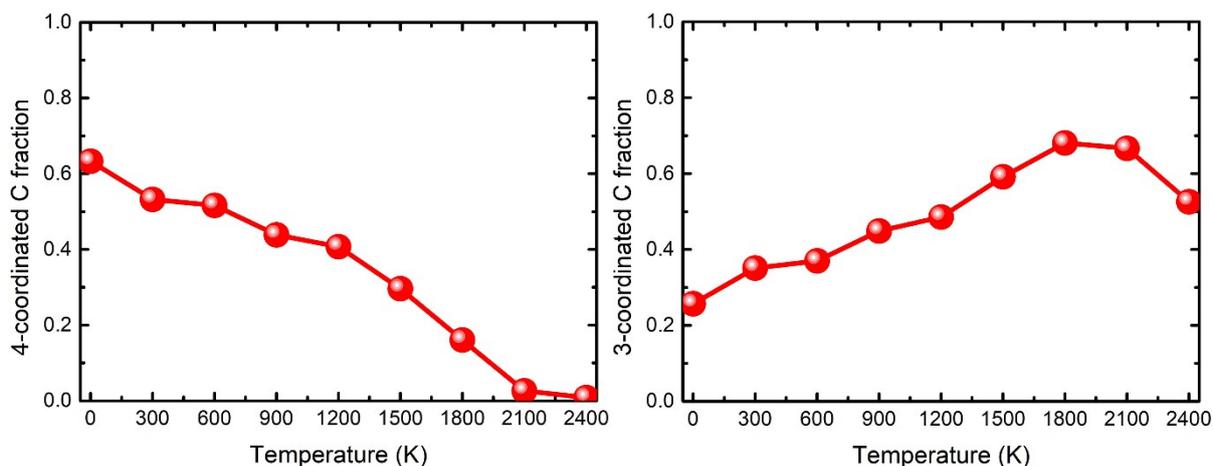


Fig. S4. Hybridization fraction of a-C structure with temperature.

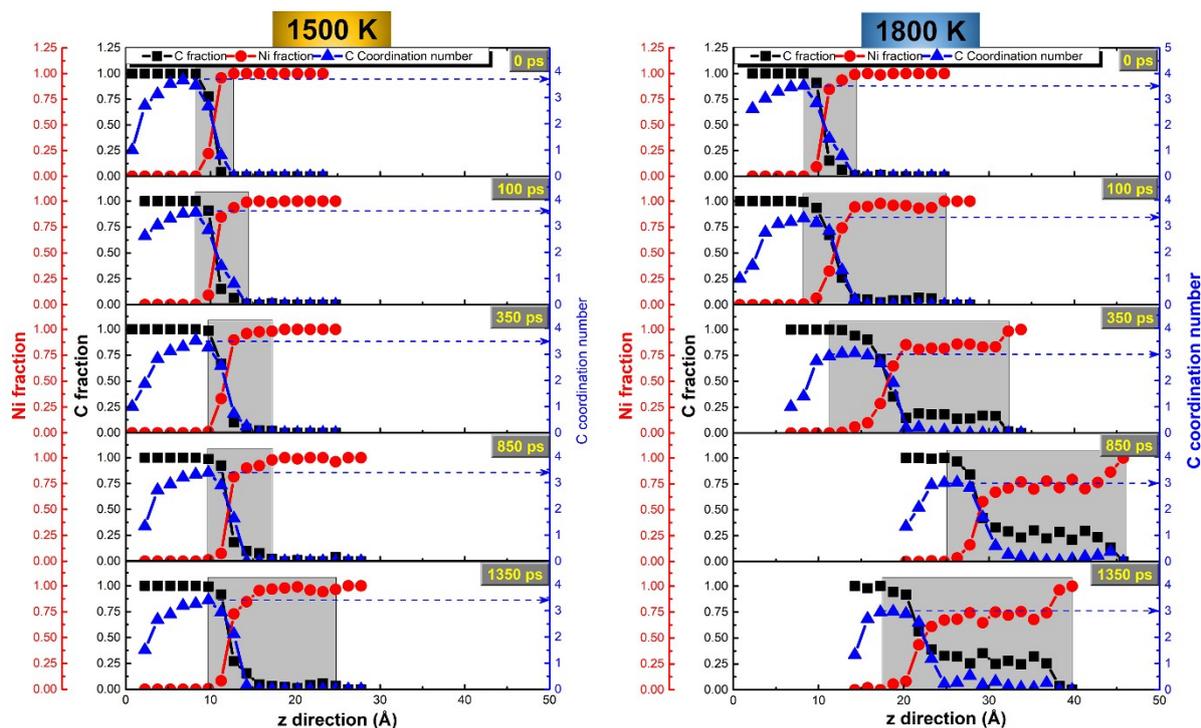
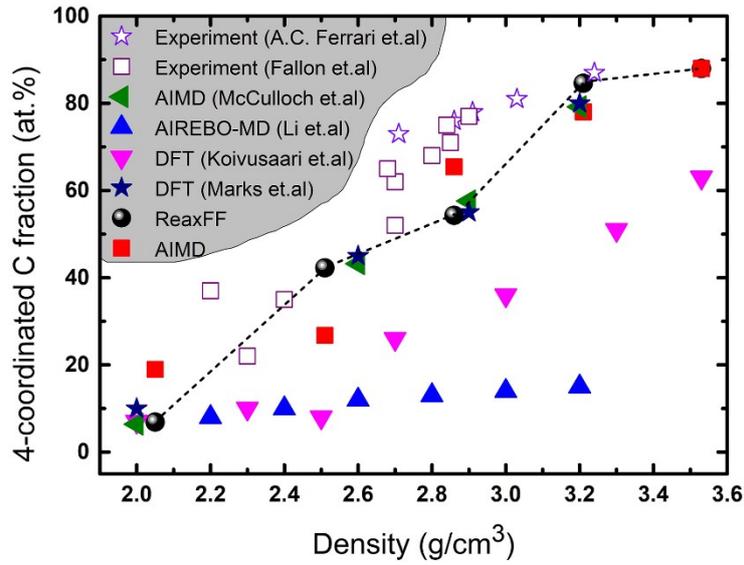


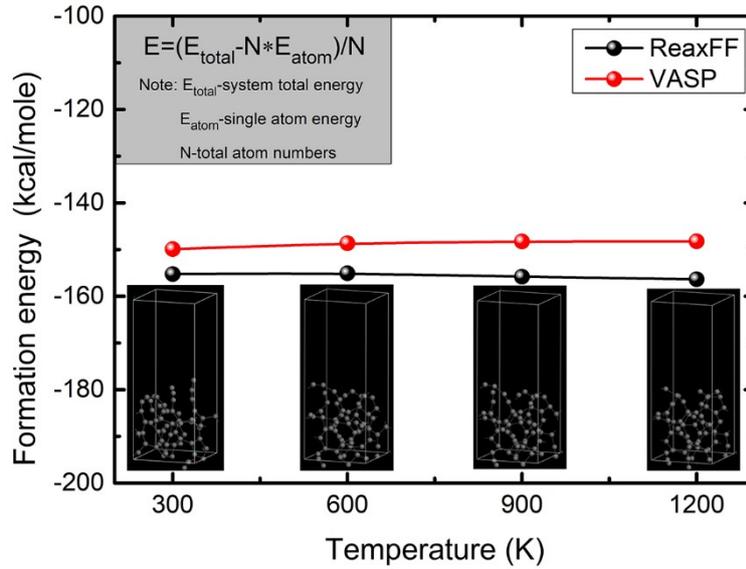
Fig. S5. Distributions of C and Ni atomic fractions along the diffusion couple direction when the system is diffused at 1500 K and 1800K for 1350 ps, respectively.

## S2. Validation for ReaxFF potential

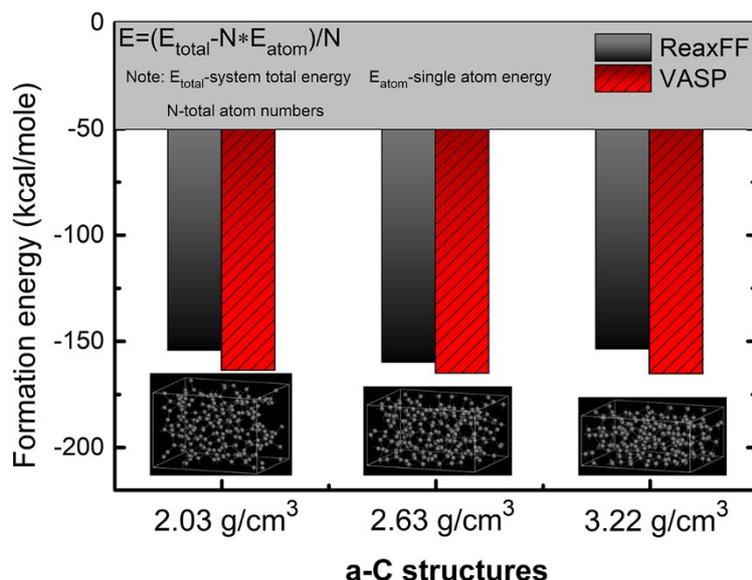
ReaxFF potential developed by Mueller *et al.*<sup>1</sup> is used to describe the interaction between the C and Ni atoms, which is able to model the bond forming/breaking, atom arrangement/rehybridization, chemical reactions and phase transformation accurately in carbon-based structures. Although it has been proved to be suitable for our system in previous calculation, many additional calculations for this potential including the fabrication of a-C structure (Fig. S6) using quenching method,<sup>2</sup> the temperature-dependence of formation energy of a-C structure (Fig. S7), the formation energies of a-C structures with different densities (Fig. S8), the energy changes of diamond, Ni crystal, and a-C induced by expansion and compression of supercell size (Fig. S9), the surface energy of Ni crystal (Fig. S10), and the formation energies of Ni-C mixing structures generated at the different stages of the quenching process (Fig. S11) are further performed by ReaxFF MD and ab-initio calculations<sup>3,4</sup> separately to validate the reliability of the used ReaxFF potential. They clearly display that the a-C structure is well reproduced compared to our and previous density function theory (DFT) calculations<sup>5-8</sup> and experiment results,<sup>9,10</sup> as shown in Fig. S6; the energy changes from ReaxFF are also consistent with those from ab-initio calculations in Fig. S7~S10, and the changes of both the formation energy and radial distribution function (RDF) spectra in Fig. S11 indicate that the Ni-C interaction can be accurately described compared to the ab-initio results, suggesting the validity of the force field for our simulated Ni@a-C systems.



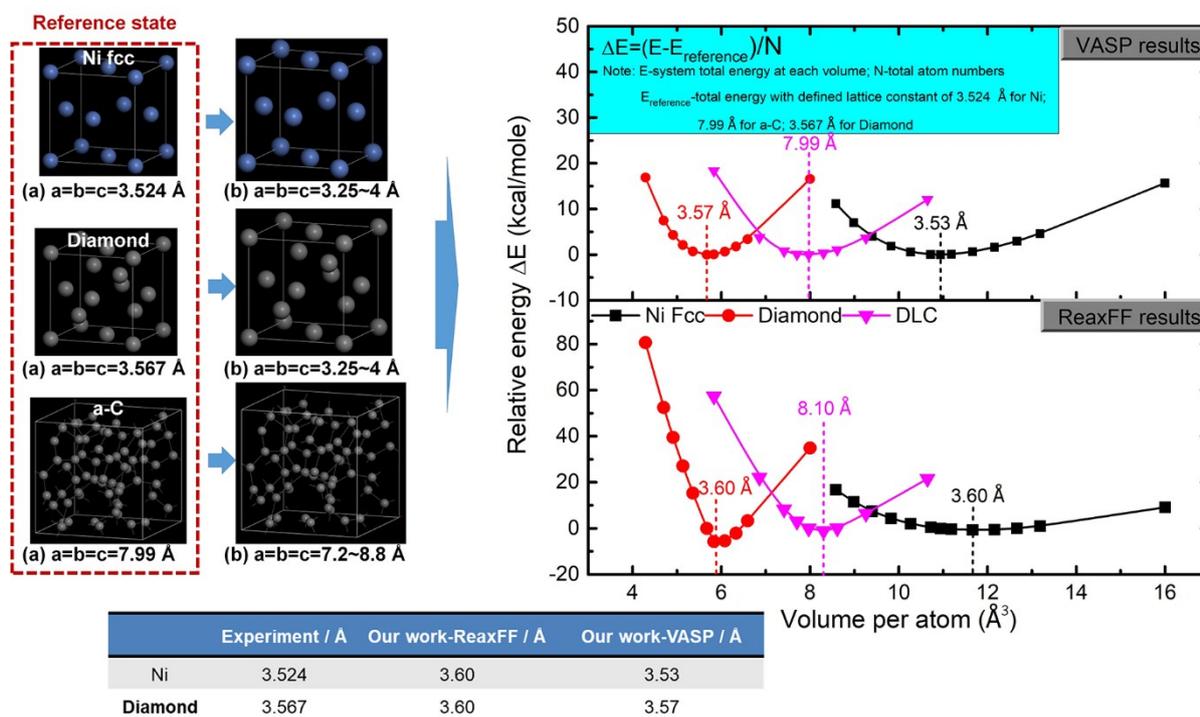
**Fig. S6.** Fabrication of a-C structure by ReaxFF MD simulation using quenching method. The results are compared with our and previous DFT calculations<sup>5-8</sup> and experiment results.<sup>9,10</sup>



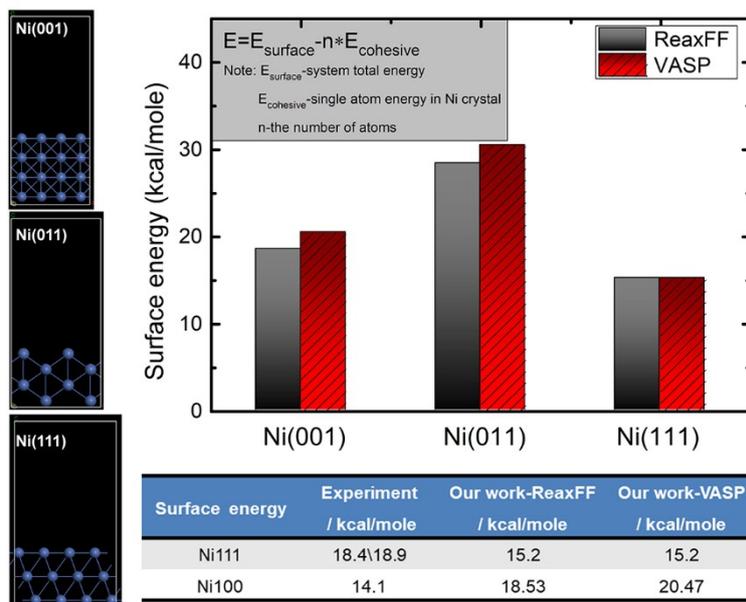
**Fig. S7.** Temperature-dependence of formation energy of a-C structure calculated by ReaxFF MD and ab-initio calculations, respectively.



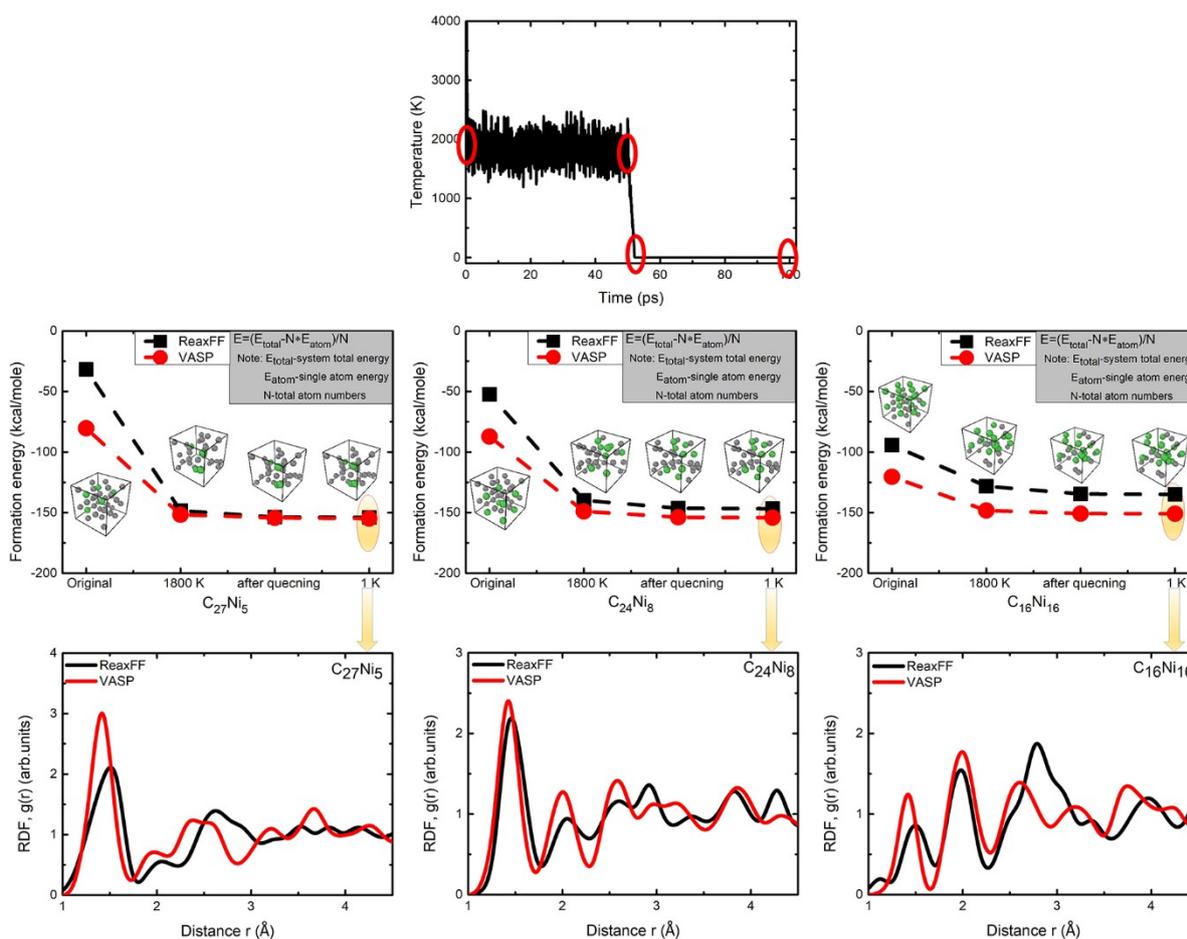
**Fig. S8.** Formation energies of a-C structures with different densities calculated by ReaxFF MD and ab-initio calculations, respectively.



**Fig. S9.** Energy changes of diamond, Ni crystal, and a-C induced by expansion and compression of supercell size, which were calculated by ReaxFF MD and ab-initio calculations, respectively. The experimental values are also give for comparison.<sup>1</sup>



**Fig. S10.** Surface energy of Ni crystal calculated by ReaxFF MD and ab-initio calculations, respectively. The experimental values are also give for comparison.<sup>1</sup>



**Fig. S11.** Formation energies and RDF spectra of Ni-C mixing structures generated at the different stages of quenching

process.

## References

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